

FORM PTO-1449  U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE  LIST OF REFERENCES CITED BY APPLICANT  (Use several sheets if necessary)	ATTY. DOCKET NO. 58620.00010	SERIAL NO. 10/830,133 <del>New Application</del>
	APPLICANT SBERVEGLIERI et al	
	FILING DATE April 23, 2004	GROUP 2856 <del>Not yet assigned</del>

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
AA						

## OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

/JF/	AL	Sberveglieri et al, "Highly Sensitive and Selective NO <sub>x</sub> and NO <sub>2</sub> Sensor Based on Cd-doped SnO <sub>2</sub> Thin Films," Sensors and Actuators B, 4, 1991, pages 457-461.
	AM	Sberveglieri et al, "A new technique for the preparation of highly sensitive hydrogen sensors based on SnO <sub>2</sub> (Bi <sub>2</sub> O <sub>3</sub> ) thin films," Sensors and Actuators B, 5, 1991, pages 253-255.
	AN	Sberveglieri et al, "A new technique for growing porous SnO <sub>2</sub> (Bi <sub>2</sub> O <sub>3</sub> ) thin films as hydrogen gas sensors," Journal of Materials Science Letters 10, 1991, pages 602-604.
		Sberveglieri et al, "A novel PVD technique for the preparation of SnO <sub>2</sub> thin films as C <sub>2</sub> H <sub>5</sub> OH Sensors," Sensors and Actuators B, 7, 1992, pages 721-726.
		Sberveglieri et al, "R.G.T.O: A New Technique for Preparing SnO <sub>2</sub> Sputtered Thin Film as Gas Sensors." IEEE, vol. 5, 1991, pages 165-168.
		Sberveglieri, "Classical and novel techniques for the preparation of SnO <sub>2</sub> thin-film gas sensors", Sensors and Actuators B, 6, 1992, pages 239-247.
		Sberveglieri et al, "Detection of Sub-ppm H <sub>2</sub> S concentrations by means of SnO <sub>2</sub> (Pt) thin films, grown by the RGTO technique", Sensors and Actuators B, 15-16, 1993, pages 86-89.
		Sberveglieri, "Novel Trends in the development of semiconducting thin films for gas sensing", Books of Abstracts, International Workshop on New Developments in Semiconducting Gas Sensors, September 13-14, 1993.
		Sberveglieri et al, "WO3 sputtered thin films for NO <sub>x</sub> monitoring", Abstract Eurosensors VIII, September 25-28, 1994.
		Sberveglieri, "Recent developments in semiconducting thin-film gas sensors", Sensors and Actuators B, 23, 1995, pages 103-109.
		Sberveglieri et al, "A Novel Method for the Preparation of Nanosized TiO <sub>2</sub> Thin Films" Advanced Materials, 1996, vol. 8, no. 4, pages 334-337.
		Ferroni et al, "Gas-Sensing Applications of W-Ti-O-based nanosized thin films prepared by r.f. reactive sputtering", Sensors and Actuators B, 44, 1997, pages 499-502.
		Faglia et al, "Electrical and structural properties of RGTO-In <sub>2</sub> O <sub>3</sub> sensors for ozone", Sensors and Actuators B 57, 1997, pages 188-191
		Comini et al, "Carbon monoxide response of molybdenum oxide thin films deposited by different techniques", Sensors and Actuators B 68, 2000, pages 168-174.
↓		Comini et al, "Ti-W-O sputtered thin film as n- or p-type gas sensors", Sensors and Actuators B 70, 2000, pages 108-114.
/JF/		Comini et al, "Production and characterization of titanium and iron oxide nano-sized thin films", J. Mater. Res., vol. 16, no. 6, June 2001, pages 1559-1564.

EXAMINER /John Fitzgerald/	DATE CONSIDERED 08/10/2007
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO.

58620.00010

SERIAL NO.

10/830,133

## LIST OF REFERENCES CITED BY APPLICANT

(Use several sheets if necessary)

APPLICANT

Giorgio SBERVEGLIERI et al.

FILING DATE

April 23, 2004

GROUP

~~1753~~ 2856

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
/JF/	AA	4,338,281	July 6, 1982	Treitinger et al.			
/JF/	AB	4,389,373	June 21, 1983	Linder et al.			
/JF/	AC	4,457,161	July 3, 1984	Iwanaga et al.			
/JF/	AD	5,367,283	November 22, 1994	Lauf et al.			
	AE						
	AF						

## FOREIGN PATENT DOCUMENTS

		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION YES NO PART.		
	AG								
	AH								
	AI								
	AJ								
	AK								

## OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

	AL	
	AM	
	AN	
EXAMINER	/John Fitzgerald/	DATE CONSIDERED 08/10/2007

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.